Special Issue

Micro/Nano Manufacturing Processes: Theories and Optimization Techniques

Message from the Guest Editors

This Special Issue aims to study some essential issues about theories and optimization techniques in the micro/nano manufacturing processes. Original research articles and reviews are welcome. Research areas may include (but are not limited to) the following:

- Micro/nano manufacturing technologies such as ultraprecision machining, photolithography, etching, ion beam machining, microforming, micromolding, etc.
- Theories and simulation analyses of micro/nano manufacturing;
- Molecular dynamic simulation of nano manufacturing;
- Optimization methods of micro/nano manufacturing processes;
- Size effects in micro/nano manufacturing;
- Micro/nano additive manufacturing;
- Non-conventional micro machining processes;
- Fabrication technologies and applications of nanomaterials;
- Applications of micro/nano components or systems.

Guest Editors

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Deadline for manuscript submissions

closed (31 May 2024)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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